

Supporting Material

Fabrication of Photomagnetic Carbon Surfaces via Redox Assembly

Yan-Ling Song and Chong Mou Wang

Department of Chemistry, National Taiwan Normal University, Taipei 116, Taiwan

In this work, $\text{Ru}(\text{bpy})_2(\text{phen-dione})^{2+}$ was synthesized by reacting $\text{Ru}(\text{bpy})_2\text{Cl}_2 \cdot 2\text{H}_2\text{O}$ with phen-dione in a molar ratio of 1:1.2 under a reflux in $\text{CH}_3\text{OH}/\text{H}_2\text{O}$ (volume ratio 1:1). The product was purified via recrystallization in ether prior to its application in surface modification. The X-ray structure is shown in Figure S1.

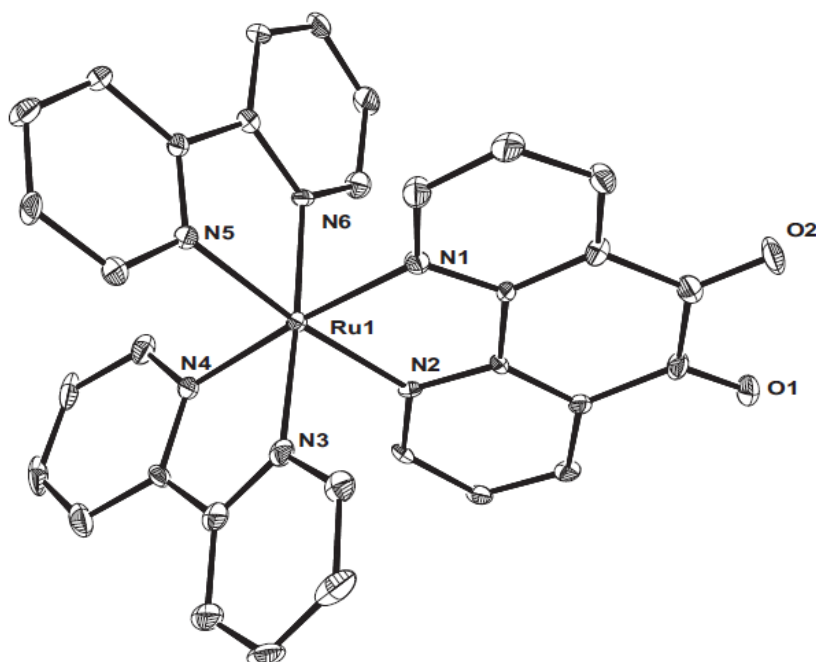


FIGURE S1: The X-ray crystal structure of $\text{Ru}(\text{bpy})_2(\text{phen-dione})^{2+}$.

For EIS analysis, data simulations were carried out based on a simplified Randles circuit (Figure S2) with the software provided by Autolab.

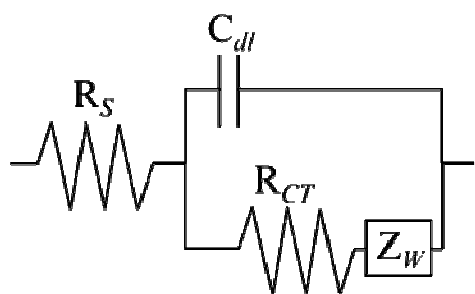


FIGURE S2: A simplified Randles circuit used for EIS data fitting.

When APBA was diazotized in acidic NaNO_2 solutions and subsequently reduced by HOPG electrodes, STM showed that nanoscale films were formed and deposited on the electrodes. $\text{Ru}(\text{bpy})_2(\text{phendione})^{2+}$ could thus be adhered to the electrodes after the phendione ligand was reduced to the corresponding alcohol. The ratio of thickness of the APBA layer to the $\text{Ru}(\text{bpy})_2(\text{phendione})^{2+}$ film was roughly 1:2. Surface scratch experiments, Figure S3, confirmed the STM results. The thickness of the APBA film was 0.25 nm, and 0.38 nm, for the ruthenium layer.

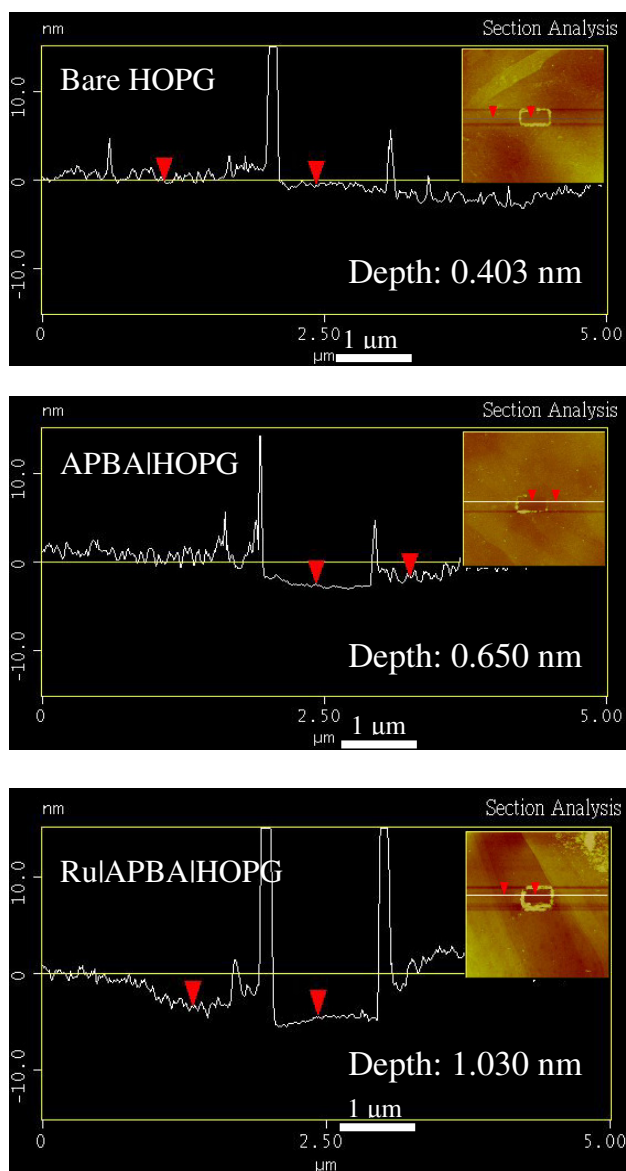


FIGURE S3: Surface scratching for bare HOPG, APBA/HOPG, and Ru/APBA/HOPG. Scan size: 5 $\mu\text{m} \times 5 \mu\text{m}$; scratch size: 1 $\mu\text{m} \times 0.5 \mu\text{m}$.

Phendione can form boronate ester with APBA after being reduced to phendiol. This reactivity was identified by in situ STM, in which the surface roughness (r) of the APBA-modified electrode increased significantly when the electrode potential (E) became more negative than 0 V vs. SCE. In contrast, trivial r was observed if APBA was excluded from the electrodes, as shown in Figure S4. The contrast indicates that APBA is an effective adhesive for $\text{Ru}(\text{bpy})_2(\text{phendione})^{2+}$ to carbon substrates.

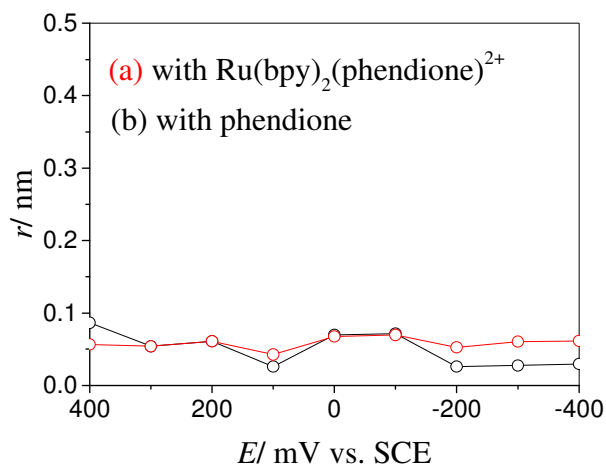
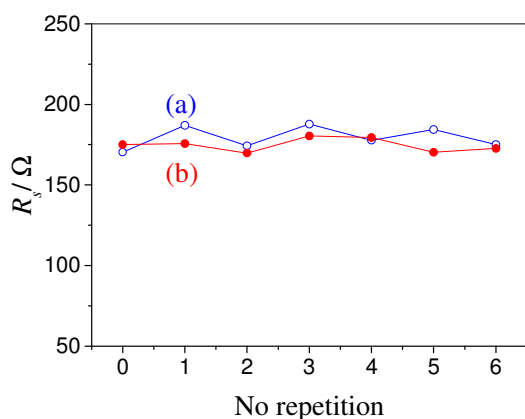


FIGURE S4: Correlations between the r of bare HOPG electrodes and E in the presence of 1 mM of $\text{Ru}(\text{bpy})_2(\text{phendione})^{2+}$ (a) or phendione (b).

EIS measurements for the R_{CT} of $\text{Fe}(\text{CN})_6^{3-/4-}$ at the HOPG electrodes showed that the solution resistance (R_s), the double-layer capacitance (C_{dl}), and the Warburg impedance (Z_w) also changed systematically with the increase in the number of repetition of the electrodes being treated with APBA and the ruthenium complex, but in a minor way. The results are shown in Figure S5 for comparison.



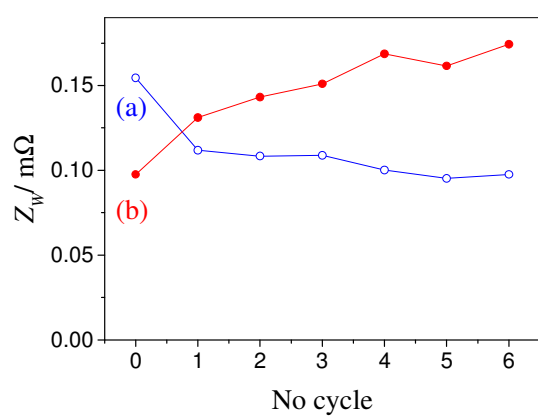
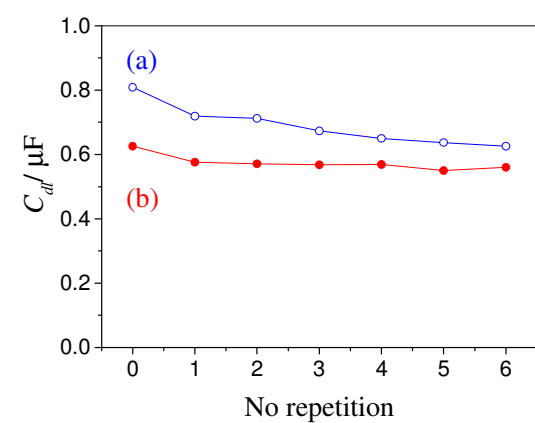


FIGURE S5: Correlations of R_s , C_{dl} , and Z_W with the number of repetitions (No.) of the HOPG electrode being treated with 1 mM APBA (a) and further with 1 mM of $\text{Ru}(\text{bpy})_2(\text{phen})^{2+}$ (b).